



INTERNATIONAL
GEMOLOGICAL
INSTITUTE

ELECTRONIC COPY

LABORATORY GROWN DIAMOND REPORT

December 13, 2025

IGI Report Number

LG756563100

Description

LABORATORY GROWN DIAMOND

Shape and Cutting Style

OVAL BRILLIANT

Measurements

9.49 X 6.36 X 4.01 MM

GRADING RESULTS

Carat Weight

1.54 CARAT

Color Grade

E

Clarity Grade

VVS 2

ADDITIONAL GRADING INFORMATION

Polish

EXCELLENT

Symmetry

EXCELLENT

Fluorescence

NONE

Inscription(s)

 LG756563100

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa

PROPORTIONS

Slightly Thick To Thick (Faceted)

12%

64%

46%

63.1%

Pointed



Sample Image Used

COLOR

D

E

F

G

H

I

J

Faint

Very Light

Light

CLARITY

FL

IF

VVS¹⁻²

VS¹⁻²

SI¹⁻²

I¹⁻³

Flawless

Internally Flawless

Very Very Slightly Included

Very Slightly Included

Slightly Included

Included



© IGI 2020, International Gemological Institute

FD - 10 20

December 13, 2025

IGI Report No LG756563100

OVAL BRILLIANT

9.49 X 6.36 X 4.01 MM

1.54 CARAT

E

VVS 2

63.1%

64%

Slightly Thick To Thick (Faceted)

Pointed

EXCELLENT

EXCELLENT

NONE

 LG756563100

Culet

Polish

Symmetry

Fluorescence

Inscription(s)

Comments: The Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa

LABORATORY GROWN DIAMOND REPORT



December 13, 2025

IGI Report Number

LG756563100

Description

LABORATORY GROWN DIAMOND

Shape and Cutting Style

OVAL BRILLIANT

Measurements

9.49 X 6.36 X 4.01 MM

GRADING RESULTS

Carat Weight

1.54 CARAT

Color Grade

E

Clarity Grade

VVS 2

ADDITIONAL GRADING INFORMATION

Polish

EXCELLENT

Symmetry

EXCELLENT

Fluorescence

NONE

Inscription(s)

 LG756563100

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa



IGI



THIS DOCUMENT WAS PRODUCED WITH THE FOLLOWING SECURITY MEASURES: SPECIAL DOCUMENT PAPER, INK SCREENS, WATERMARK BACKGROUND DESIGNS, HOLOGRAM AND OTHER SECURITY FEATURES NOT LISTED AND DO EXCEED DOCUMENT SECURITY INDUSTRY GUIDELINES.